Special Issue

Formation Mechanisms and Process Analysis of Air Pollutants

Message from the Guest Editors

This Special Issue, titled "Formation Mechanisms and Process Analysis of Air Pollutants", seeks high-quality research articles and reviews on the latest novel advances in air pollutant formation mechanisms and their process assessment for the evaluation and improvement of air quality. The topics covered in this Special Issue include, but are not limited to, the following:

- Observations and numerical simulations of air pollutants;
- Formation mechanisms of secondary air pollutants;
- Process assessment of air pollution;
- New methods for process analysis of air pollutants;
- Control strategies for air pollution.

Guest Editors

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Deadline for manuscript submissions

closed (30 May 2024)



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You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

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